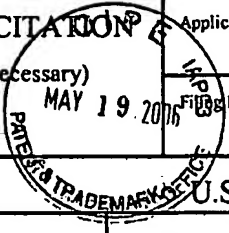


APPLICANT'S ART CITATION (Use several sheets if necessary)		Application		OFGS File No. P/2635-72			
		Applicant Toru NAKAZAWA					
		Filing Date		Group Art Unit			
U.S. PATENT DOCUMENTS							
Examiner Initial	Document Number	Date MM-YYYY	Name	Class	Sub-class	Filing Date If Appropriate	
	US-						
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	Document Number	Date MM-YYYY	Country	Class	Sub-class	Translation	
						Yes	No
/PT/	2002-330168	11/2002	Japan			No	
↓	8-8995	01/1996	Japan			No	
↓	2002-135277	05/2002	Japan			No	
↓	10-126459	05/1998	Japan			No	
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/PT/	6-252978	09/1994	Japan			No	
OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)							
Examiner	/Phuc Tran/		Date Considered 09/17/2007				
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APPLICANT'S ART CITATION (Use several sheets if necessary) MAR 20 2006 U.S. PATENT & TRADEMARK OFFICE		Application 10/780,957		OFCS File No. P/2635-72			
		Applicant Toru NAKAZAWA					
		Filing Date February 18, 2004		Group Art Unit 2661			
U.S. PATENT DOCUMENTS							
Examiner Initial	Document Number	Date MM-YYYY	Name	Class	Sub-class	Filing Date If Appropriate	
/PT/	US-2001/0015956 A1	08-2001	Ono				
	US-						
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	Document Number	Date MM-YYYY	Country	Class	Sub-class	Translation	
						Yes	No
/PT/	WO 01/93513 A2	12-2001	PCT			X	
OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)							
/PT/		List of Prior Ars for Information Disclosure Statement prepared by applicant in connection					
/PT/		with the instant application					
/PT/		Office Action issued by Chinese Patent Office on January 27, 2006 in connection with					
/PT/		corresponding Chinese application no. 200410005801.3					
/PT/		English translation of Chinese Office Action dated January 27, 2006 issued in					
/PT/		connection with corresponding Chinese applicatin no. 200410005801.3					
Examiner /Phuc Tran/		Date Considered 09/17/2007					
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APPLICANT'S ART CITATION (Use several sheets if necessary)		Application 10/780,957		OFGS File No. P/2635-72	
		Applicant Toru NAKAZAWA			
		Filing Date February 18, 2004		Group Art Unit 2661	


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	US-					
	US-					
	US-					
	US-					
	US-					
	US-					

FOREIGN PATENT DOCUMENTS

	Document Number	Date MM-YYYY	Country	Class	Sub-class	Translation	
						Yes	No
/PT/	2003-0008324	01-2003	Korea				X

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

/PT/		List of Prior Arts for Information Disclosure Statement prepared by Korean associate
↓		<i>Bounds on the Throughput Performance of ARQ Selective-Repeat Protocol in Markov Channels</i> , M. Zorzi, et. al., ICC 96, Vol. 2, pp. 782-786
↓		Office Action issued by Korean Patent Office on January 31, 2006 in connection with corresponding Korean application no. 10-2004-0010692
↓		Japanese translation of Korean Office Action dated January 31, 2006 issued in connection with corresponding Korean application no. 10-2004-0010692
↓		English translation of Japanese translation of Korean Office Action dated January 31, 2006 issued in connection with corresponding Korean application no. 10-2004-0010692
/PT/		

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